

Electronic Patent Application Fee Transmittal

Application Number:	10720097			
Filing Date:	25-Nov-2003			
Title of Invention:	Process for forming resist pattern, semiconductor device and fabrication thereof			
First Named Inventor/Applicant Name:	Miwa Kozawa			
Filer:	Kenneth H. Salen./Renita Flood			
Attorney Docket Number:	032132			
Filed as Large Entity				
Utility Filing Fees				
Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Basic Filing:				
Pages:				
Claims:				
Miscellaneous-Filing:				
Petition:				
Patent-Appeals-and-Interference:				
Post-Allowance-and-Post-Issuance:				
Extension-of-Time:				
Extension - 2 months with \$0 paid	1252	1	460	460

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Miscellaneous:				
Request for continued examination	1801	1	810	810
Total in USD (\$)				1270